

## Spring 2019 IEN Soft Lithography for Microfluidics Short Course

» April 18 - 19, 2019 | Marcus Nanotechnology Building

The Institute for Electronics and Nanotechnology (IEN) at Georgia Tech will offer a short course on “Soft Lithography for Microfluidics” on April 18 & 19, 2019. This course module is designed for individuals interested in hands-on training in the fabrication of microfluidic devices using the soft lithography technique. This 2 day intensive short course will be structured to assume no prior knowledge of the technologies by the participants. The course agenda is evenly divided between laboratory hands-on sessions, including SU-8 master mold creation using photolithography and PDMS device fabrication in the IEN cleanroom, and supporting lectures. The goal for this course is to impart a basic understanding of soft lithography for microfluidic applications as practiced in academia and industry.

» **Rates: \*rates include lunch on both days\***

- Georgia Tech Rate: \$150
- Academic and Government Rate: \$300
- Industry Rate: \$600

**Registration:**

Due to the nature of the lab portion of the course, registration has a maximum of 15 participants. Your registration is not guaranteed until full payment is received. If you wish to charge the course to an IEN Cleanroom account, please contact us immediately so that we can provide the proper forms, and so that we may notify the PI or accounts representative. Credit cards are the only payment option for people outside Georgia Tech. Once you submit your registration, follow the appropriate links in your confirmation email. A waiting list of overflow registrants will be maintained in case of cancellations.

» **REGISTER FOR THE COURSE AT: [ien.gatech.edu/s2019-sl](http://ien.gatech.edu/s2019-sl)**



Contact: Dr. Paul Joseph, Ph.D.  
Principal Research Scientist  
[paul.joseph@ien.gatech.edu](mailto:paul.joseph@ien.gatech.edu)  
(404)-894-3360